L Number	Hits	Search Text	DB	Time stamp
1	50081	(electron adj beam) and substrate	USPAT;	2004/04/22 11:14
			US-PGPUB;	
			EPO; JPO;	
			IBM_TDB	
2	14196	((electron adj beam) and substrate) and stage	USPAT;	2004/04/22 11:14
			US-PGPUB,	
			EPO; JPO;	
			IBM_TDB	
3	2841	(((electron adj beam) and substrate) and stage) and focus	USPAT;	2004/04/22 11:14
			US-PGPUB;	
			EPO; JPO;	
			IBM_TDB	
4	98	((((electron adj beam) and substrate) and stage) and focus)	USPAT;	2004/04/22 11:15
		and (surface adj charge)	US-PGPUB;	
			EPO; JPO;	
ľ			IBM_TDB	
5	96	(((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:15
		focus) and (surface adj charge)) and area	US-PGPUB;	' '
			EPO; JPO;	
İ			IBM_TDB	
6	96	(((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:15
		focus) and (surface adj charge)) and area	US-PGPUB;	
į			EPO; JPO;	
			IBM_TDB	
7	52	((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:16
1		focus) and (surface adj charge)) and area) and bias	US-PGPUB;	., .,
			EPO; JPO;	
			IBM_TDB	
8	25	((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:16
		focus) and (surface adj charge)) and area) and (bias adj	US-PGPUB;	
		voltage)	EPO; JPO;	
		J ,	IBM_TDB	
9	25	(((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:17
-		focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	
		(bias adj voltage)	EPO; JPO;	
		,	IBM_TDB	
10	1	((((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:38
_	_	focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	
		(bias adj voltage)) and (bias near4 level)	EPO; JPO;	
		, , , , , , , , , , , , , , , , , , , ,	IBM_TDB	
11	25	((((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:39
		focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	
		(bias adj voltage)) and level	EPO; JPO;	
			IBM_TDB	
12	25	((((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:39
		focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	
		(bias adj voltage)) and voltage	EPO; JPO;	
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L Number	Hits	Search Text	DB	Time stamp
1	6	((((((((((((((((((((((((((((((((((((((USPAT;	2004/04/22 14:13
		focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	
		(bias adj voltage)) and level) and flood	EPO; JPO;	
			IBM_TDB	
2	1	"20020130260"	USPAT;	2004/04/22 14:15
	-		US-PGPUB;	
			EPO; JPO;	
			IBM_TDB	
	E0001	(clastron adi hoam) and substrato		2004/04/22 11:14
-	50081	(electron adj beam) and substrate	USPAT;	2004/04/22 11:14
			US-PGPUB;	
			EPO; JPO;	
			IBM_TDB	
-	14196	((electron adj beam) and substrate) and stage	USPAT;	2004/04/22 11:14
			US-PGPUB;	
			EPO; JPO;	
			IBM_TDB	
-	2841	(((electron adj beam) and substrate) and stage) and focus	USPAT;	2004/04/22 11:14
1		\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\\	US-PGPUB;	
ł			EPO; JPO;	
			IBM_TDB	
	00	((((alastron adi boam) and substrate) and stage) and feeting		2004/04/22 11:15
-	98	((((electron adj beam) and substrate) and stage) and focus)	USPAT;	2004/04/22 11:15
		and (surface adj charge)	US-PGPUB;	
			EPO; JPO;	
			IBM_TDB	
-	96	(((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:15
		focus) and (surface adj charge)) and area	US-PGPUB;	
			EPO; JPO;	
			IBM_TDB	
_	96	(((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:15
1	30	focus) and (surface adj charge)) and area	US-PGPUB;	200 1,0 1,22 22120
		locus, and (surface adjuriarge), and area	EPO; JPO;	
1				
	5 0	/////	IBM_TDB	2004/04/22 11:10
-	52	((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:16
		focus) and (surface adj charge)) and area) and bias	US-PGPUB;	
			EPO; JPO;	
Ì			IBM_TDB	
-	25	((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:16
		focus) and (surface adj charge)) and area) and (bias adj	US-PGPUB,	
		voltage)	EPO; JPO;	
		,	IBM_TDB	
-	25	((((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:17
	23	focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	200 1/0 1/22 11.1/
		(bias adj voltage)	EPO; JPO;	
			IBM_TDB	2004/04/22 44 22
-	1	((((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:38
		focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	
		(bias adj voltage)) and (bias near4 level)	EPO; JPO;	
			IBM_TDB	
-	25	((((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 11:39
		focus) and (surface adj charge)) and area) and bias) and	US-PGPUB;	
		(bias adj voltage)) and voltage	EPO; JPO;	
		(and any toiming) and toiming	IBM_TDB	
-	25	(((((((((electron adj beam) and substrate) and stage) and	USPAT;	2004/04/22 14:04
	23	focus) and (surface adj charge)) and area) and bias) and		בטטדןטדן בע בדיטק
			US-PGPUB;	
		(bias adj voltage)) and level	EPO; JPO;	
			IBM_TDB	1